

PATENT

Amty. Dkt. No. AMAT/5B19/DSM/LOW KJW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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JAN 06 2005

In re Application of:
Nguyen, et al.

Serial No.: 09/912,103

Confirmation No.: 4476

Filed: July 23, 2001

**For: Selective Etching of
Organosilicate Films Over
Silicon Oxide Stop Etch
Layers**

Group Art Unit: 2823

Examiner: Khiem D. Nguyen

MAIL STOP AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

CERTIFICATE OF FAX 37 CFR 1.8	
I hereby certify that this correspondence and the documents referred to as attached therein are being facsimile transmitted to the U.S. Patent and Trademark Office to the fax number indicated by the Examiner, namely, fax number 703-872-9308 to the attention of the named Examiner, on the date below.	
Date <u>1/6/05</u>	Signature <u>James R. Zales</u>

Dear Sir:

RESPONSE TO FINAL OFFICE ACTION DATED NOVEMBER 9, 2004

In response to the Final Office Action dated November 9, 2004, having a shortened statutory period for response set to expire on February 9, 2005, please enter this response and reconsider the claims pending in the application for reasons discussed below. Although Applicant believes that no additional fees are due in connection with this response, the Commissioner is hereby authorized to charge counsel's Deposit Account No. 20-0782/AMAT/5619/KMT, for any fees, including extension of time fees or excess claim fees, required to make this response timely and acceptable to the Office.

The Pending Claims are reflected in the listing of claims which begins on page 2 of this paper. Remarks begin on page 6 of this paper.

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